Sir:

Transmitted herewith for filing is the Patent Application of:

Inventor: SHIH WEI WANG, CHIA-DAR HSIEH

ENDURANCE IMPROVEMENT BY SIDEWALL NITRIDATION OF POLY FLOATING GATE FOR NONVOLATILE For: MEMORY DEVICES USING SUBSTRATE OR DRAIN-SIDE ERASE SCHEME

Enclosed are:						
X 5 sheets of di	5 sheets of drawing(s) - formal.					
X An assignmer	An assignment of the invention to Taiwan Semiconductor Manufacturing Co.					
An associate	power of attorney	Applicant claims s	small entity status			
Request & Co	ertification under 35 US	SC 122(b)(2)(b)(i)				
The filing fee has been	calculated as shown bel	low:				
	(Col. 1)	(Col. 2)	OTHER THAN A	A SMALL ENTITY		
FOR:	NO. FILED	NO. EXTRA	RATE	FEE		
BASIC FEE	><	><		\$ 770.		
TOTAL CLAIMS	41 -20=	21	x 18 =	\$ 378.		
INDEP CLAIMS	4 -3=	1	x 86 =	\$ 86.		
		S	SUB TOTAL	\$ 1,234.		
			ASSIGNMENT	\$40.		
			TOTAL	\$ 1,274.		
Please charge my Deposit Account No. 19-0033 in the amount of \$ 1,274. A duplicate copy of this sheet is enclosed.						
The Commis	sioner is hereby authori	zed to charge paymen	t of the following fees ass	ociated with this comm	nunication or credit any	
overpayment	to Deposit Account No	o. 19-0033. A duplica	te copy of this sheet is end	closed.		
X /	Any additional filing fee	es required under 37 C	CFR §1.16.			
\mathbf{x}	Any patent application p	processing fees under	37 CFR §1.17.			
			Respectfully submitted,	_		
			STEPHEN B. ACKERM	1AN, REG. NO. 37,76	1	
		EXPRESS	MAIL CERTIFICATE			
	is correspondence is bei		United States Postal Serv			

of deposit